



Patent
Attorney's Docket No. 027260-295

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of)
Kazuya KAMON) Group Art Unit: 1756
Application No.: 09/320,946) Examiner: S. Mohamedulla
Filed: May 26, 1999)
For: PHOTOMASK, FABRICATION)
METHOD OF PHOTOMASK, AND)
FABRICATION METHOD OF)
SEMICONDUCTOR INTEGRATED)
CIRCUIT)

PETITION FOR EXTENSION OF TIME

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

The following extension of time is requested to respond to Office Action dated January 3, 2002:

one month to May 3, 2002; the extension fee is:

\$55.00 (215) \$110.00 (115).

The shortened statutory period has been reset by an Advisory Action dated

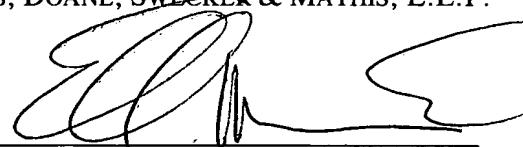
An extension fee in the amount of \$ 110.00 is enclosed.

Charge \$ to Deposit Account No. 02-4800.

The Commissioner is hereby authorized to charge any appropriate fees under 37 C.F.R. §§ 1.16, 1.17 and 1.21 that may be required by this paper, and to credit any overpayment, to Deposit Account No. 02-4800. This paper is submitted in duplicate.

Respectfully submitted,

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Date: May 3, 2002

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